

Exploring silicene monolayer as promising sensor platform to detect and capture NO and CO gas

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Table S1: Adsorption energy (eV/molecule) of XO (X = N and C) molecules onto pristine and Al-doped silicene monolayer calculated with LDA functional.

	XO	2XO1	2XO2	2XO3	2XO4	3XO	4XO
	Onto pristine silicene						
NO	-0.89	-2.00	-0.89	-0.79	-0.86	-0.93	-0.90
CO	-0.22	-0.81	-0.28	-0.13	-0.27	-0.28	-0.29
	Onto Al-doped silicene						
CO	-0.78	-1.13	-0.79	-0.82	-0.78	-0.82	-0.82

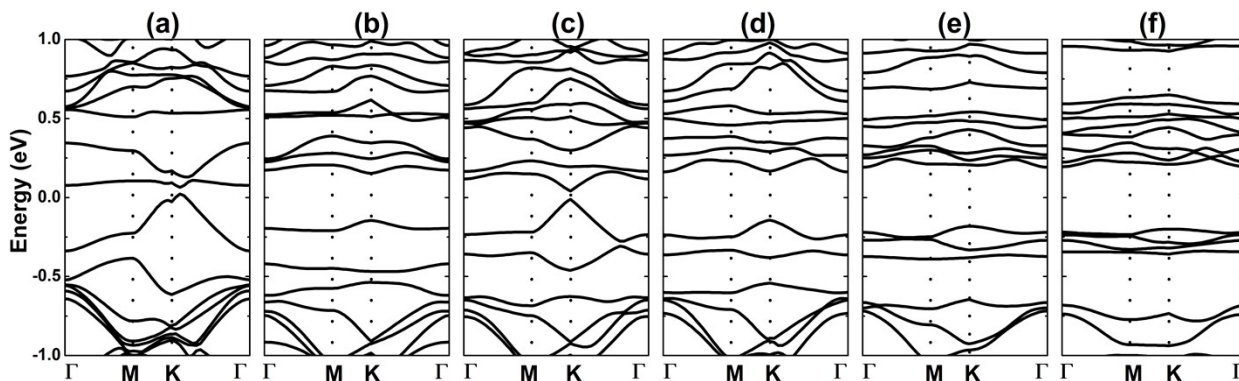


Figure S1. Electronic band structure (a) 2CO1-, (b) 2CO2-, (c) 2CO3-, (d) 2CO4-, (e) 3CO- and (f) 4CO-adsorbed silicene monolayer.

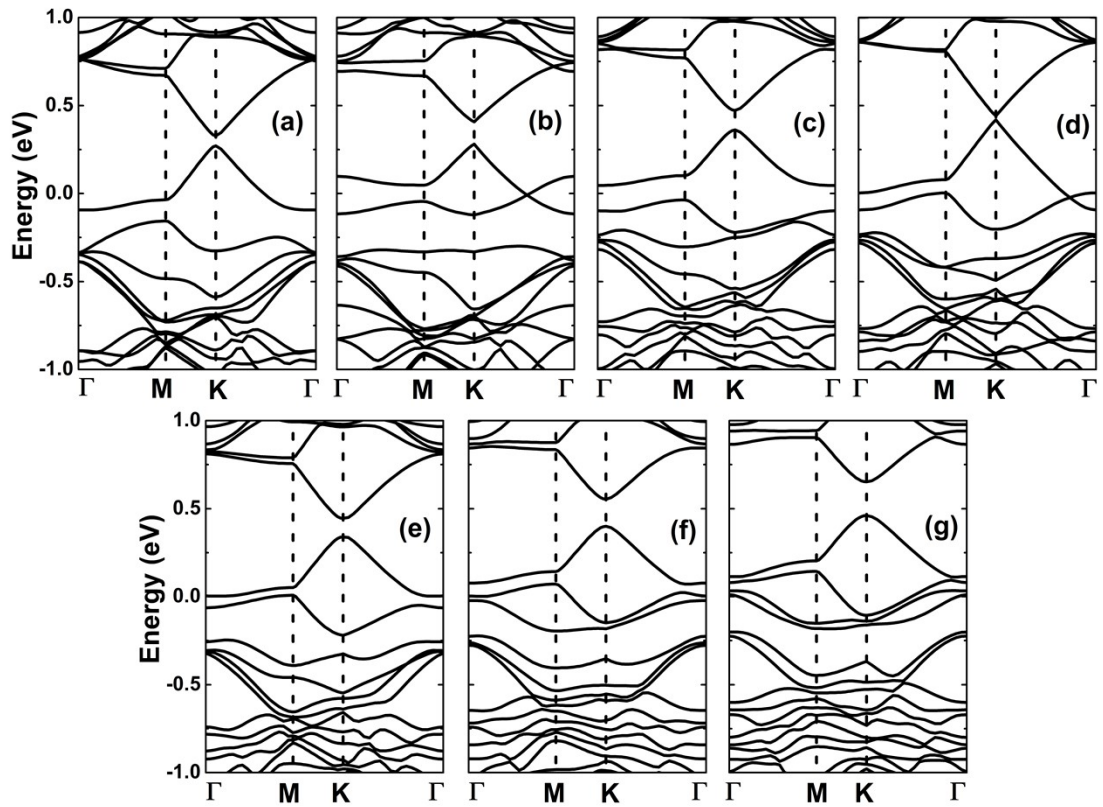


Figure S2: Band structure of (a) Al-, (b) 2Al1-, (c) 2Al2-, (d) 2Al3-, (e) 2Al4-, (f) 3Al-, and (g) 4Al-doped silicene monolayer.